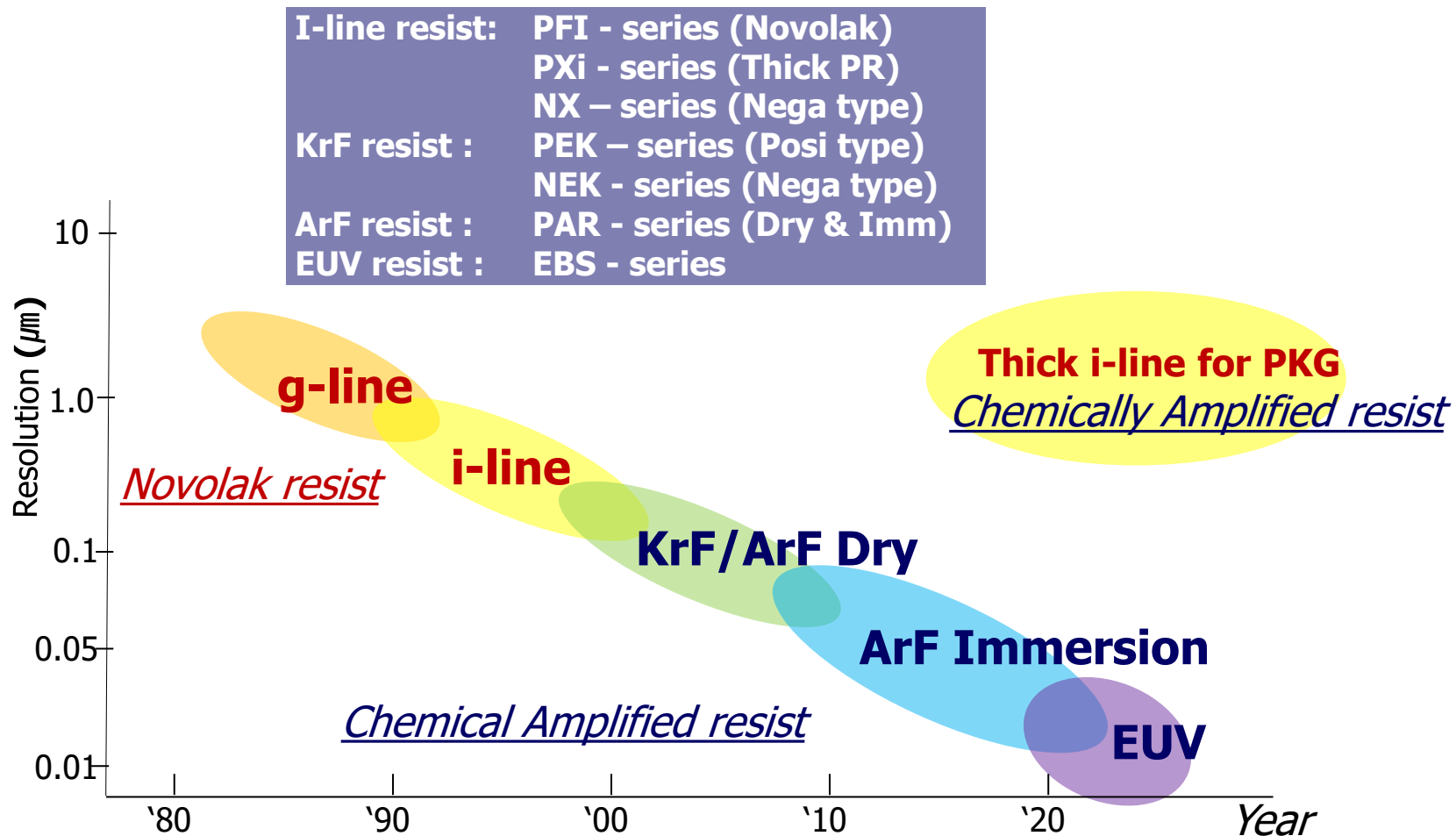
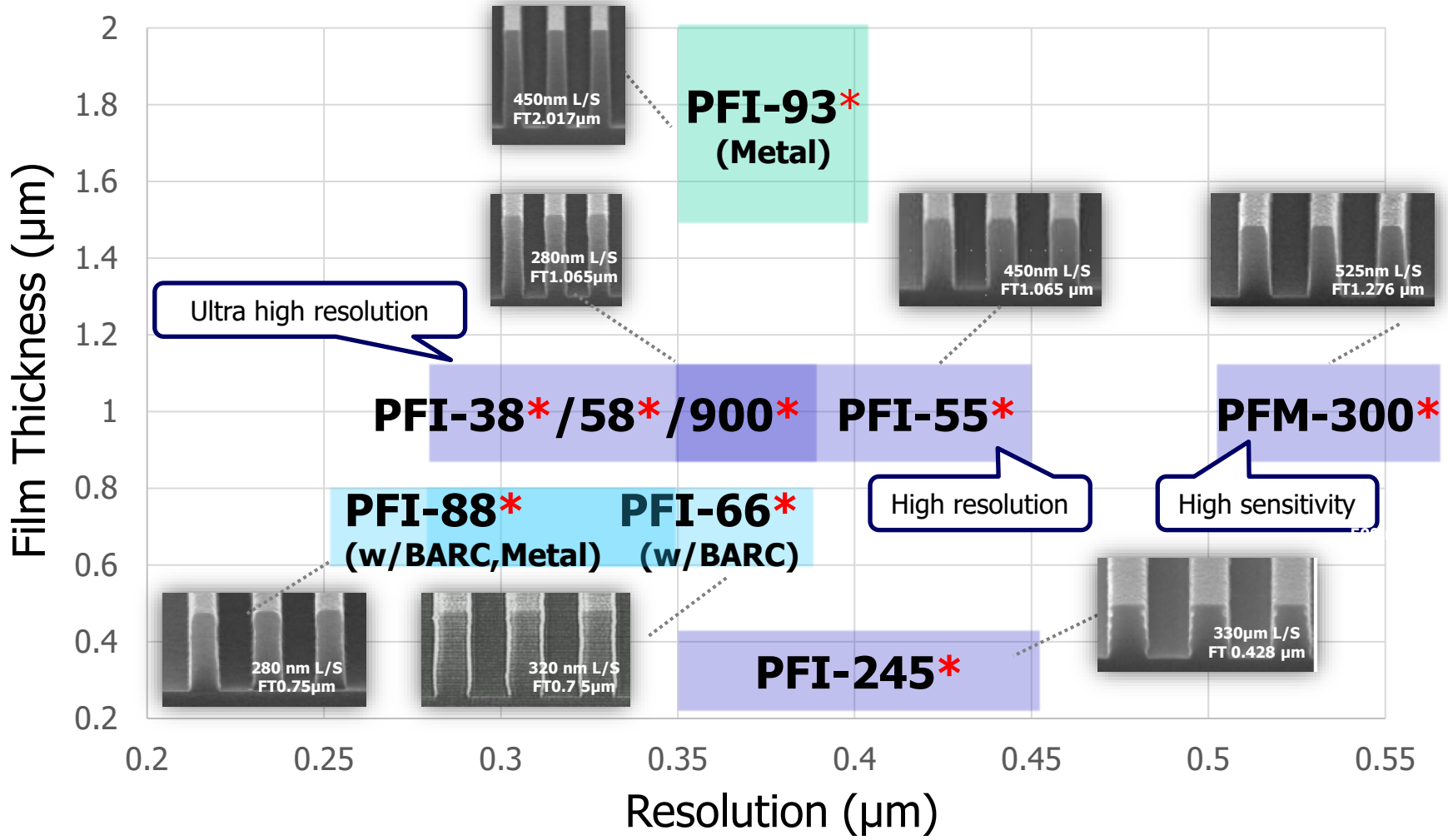


Sumitomo Chemical's SUMIRESIST™ Photoresist solution at a glance

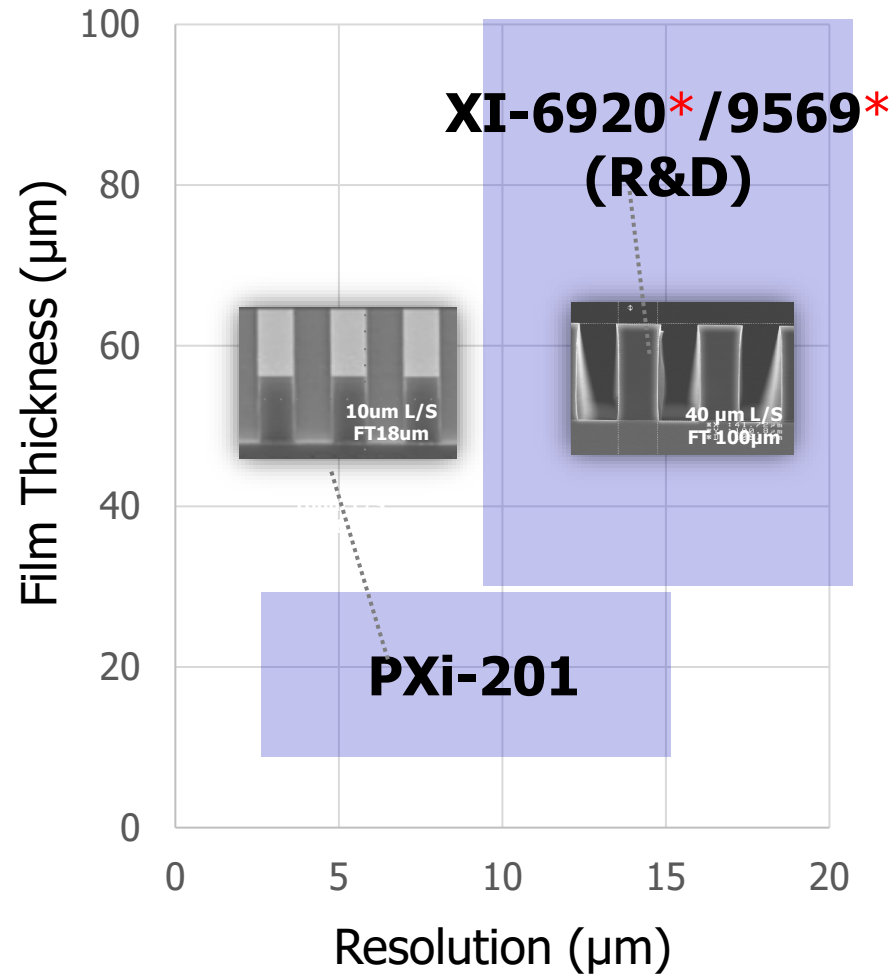
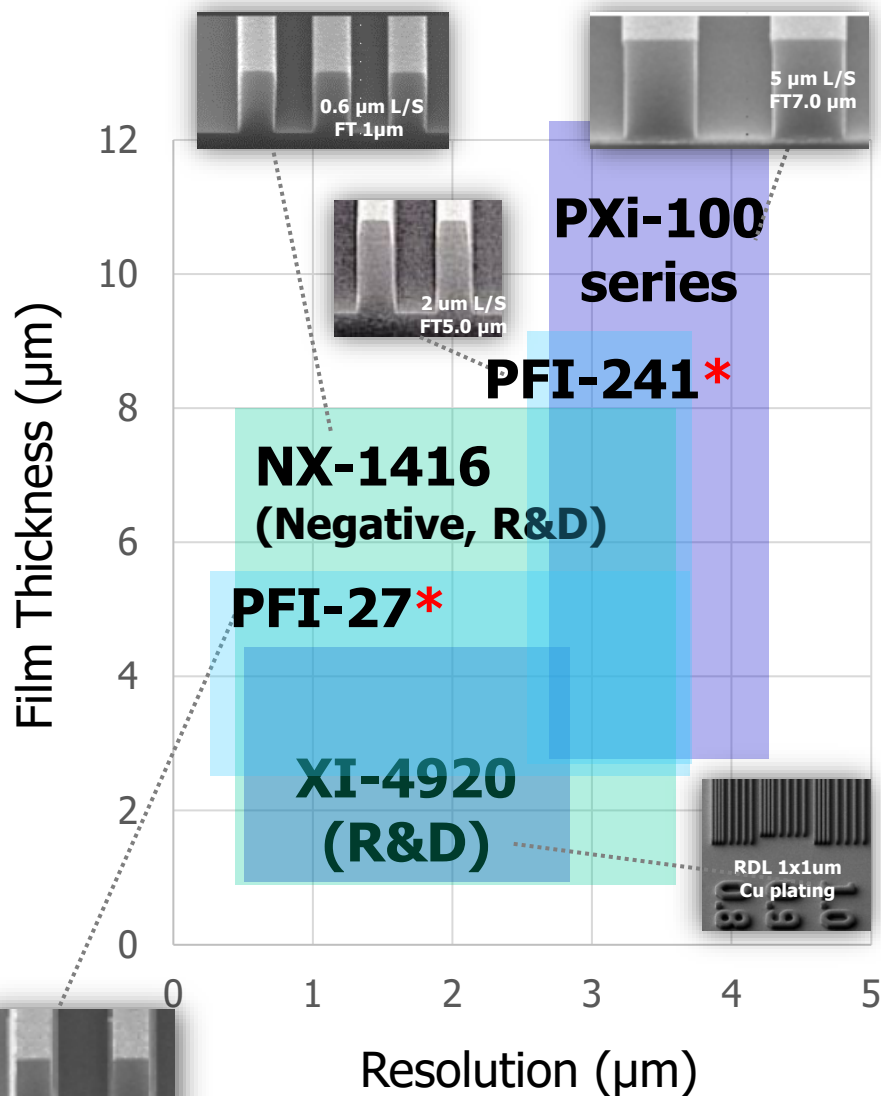


SUMIRESIST™ i-line – Positive, Thin (FT<2.0um)

PFAS-free*



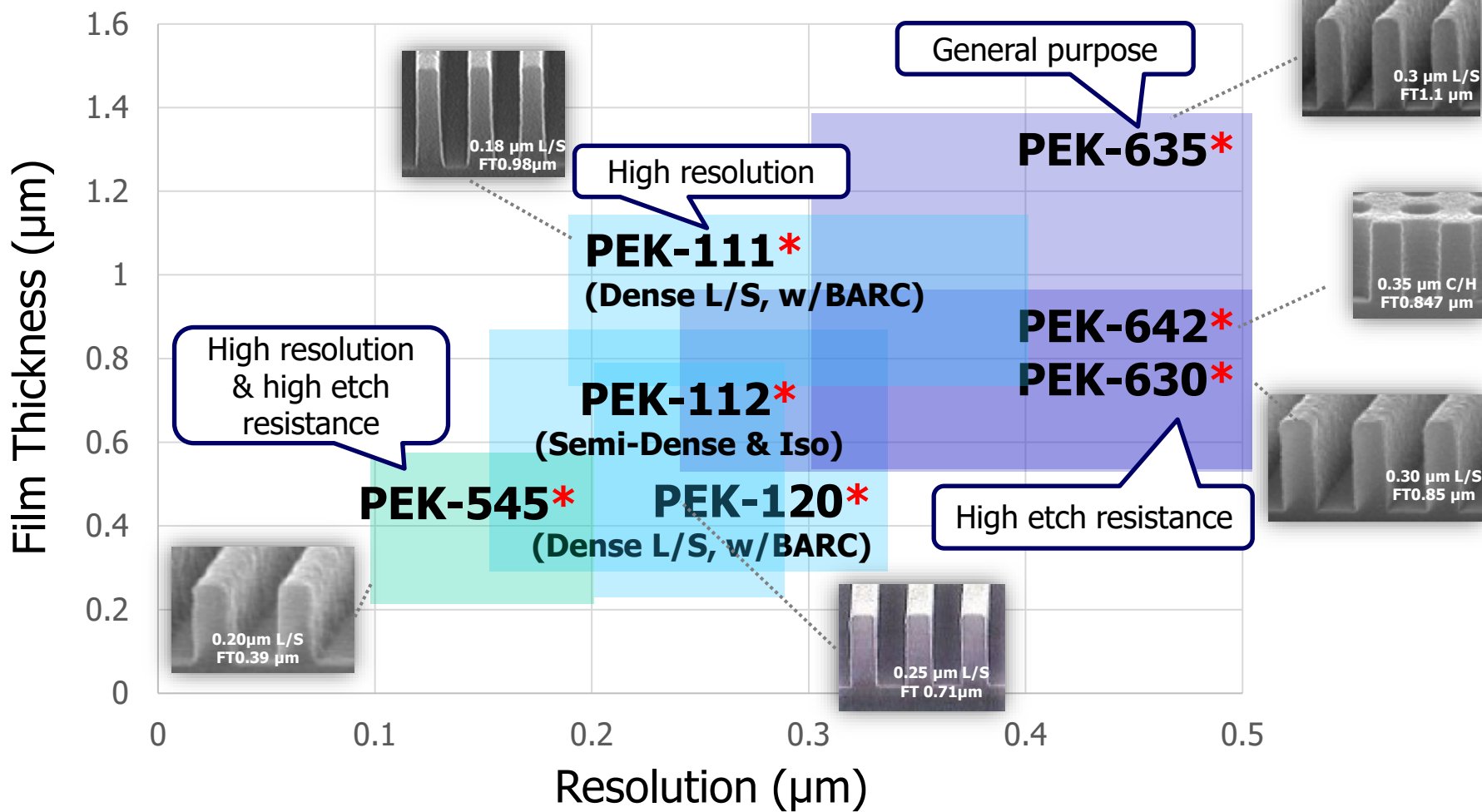
SUMIRESIST™ i-line, Thick (FT<100um)



PFAS-free*

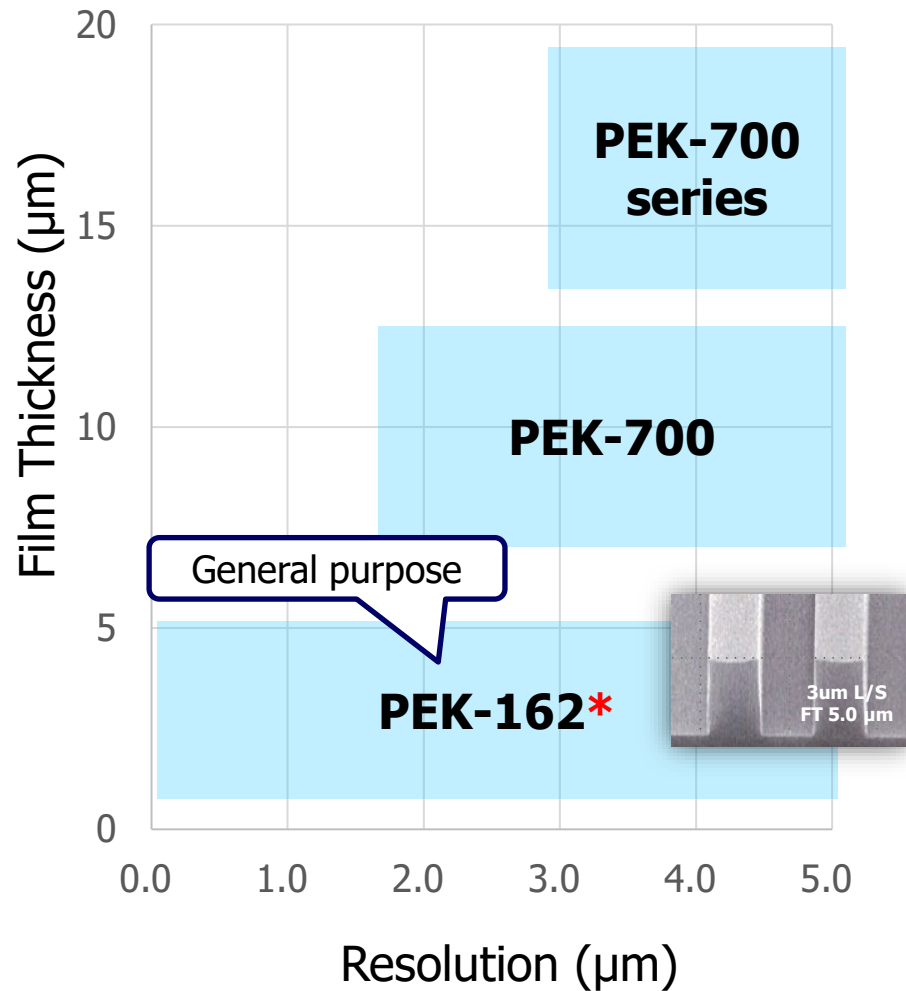
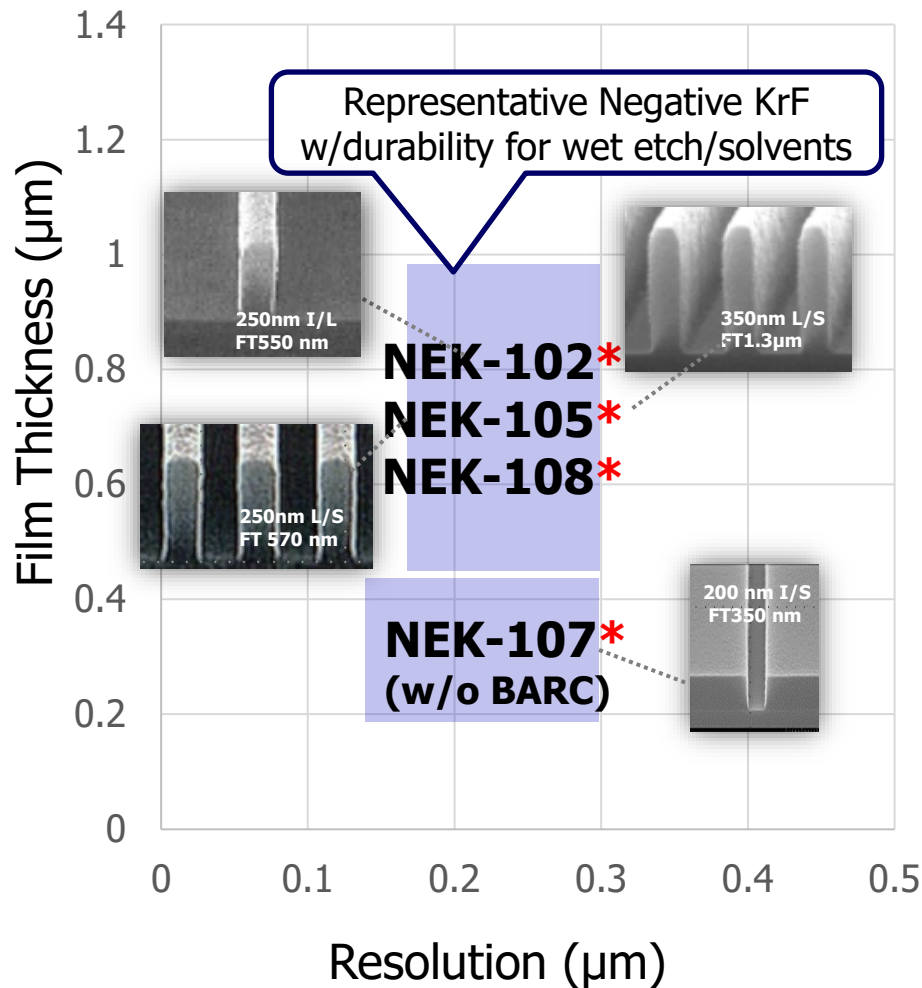
SUMIRESIST™ KrF – Positive, Thin (FT<1.5μm)

PFAS-free*



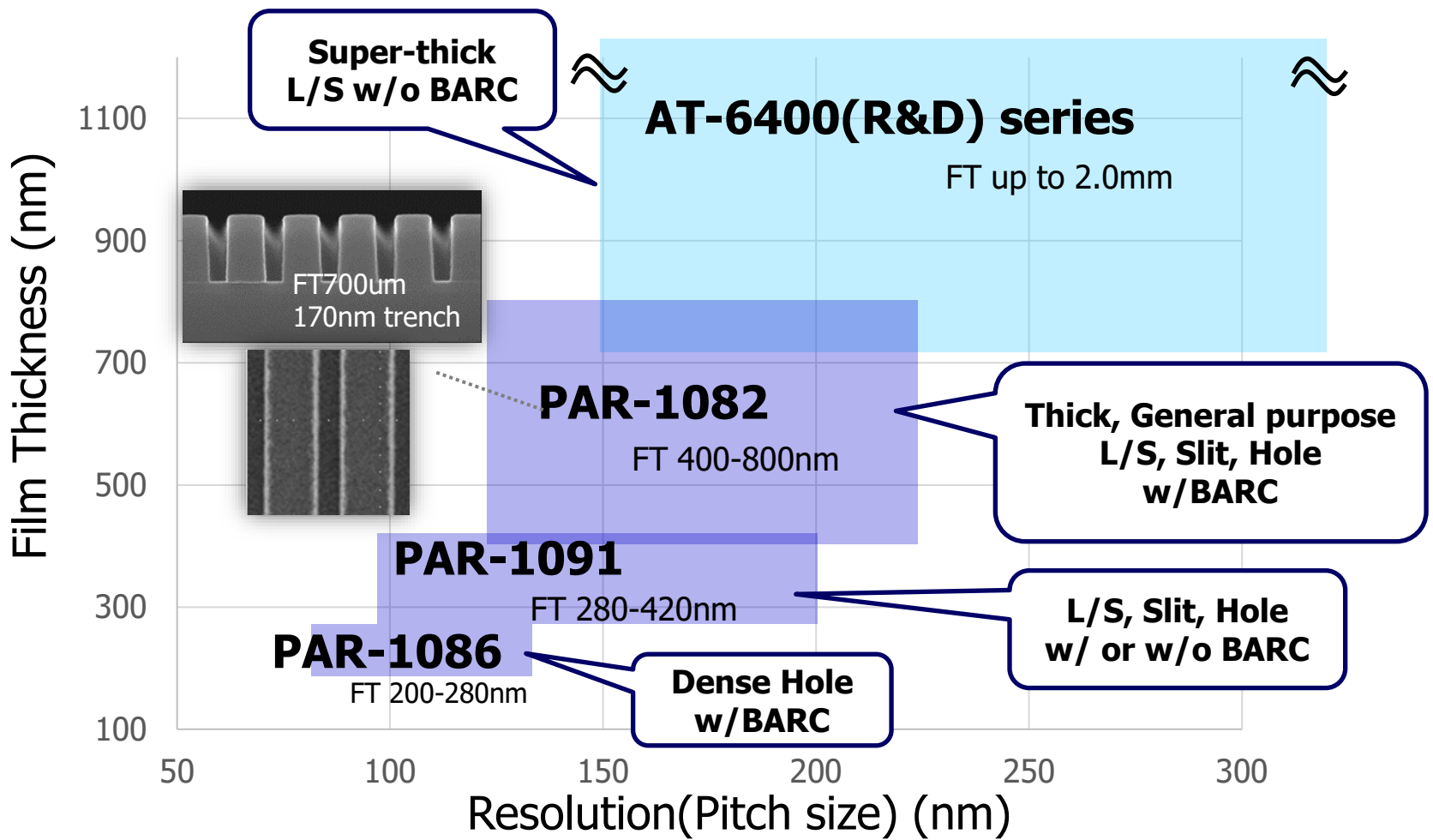
SUMIRESIST™ KrF – others

PFAS-free*



SUMIRESIST™ ArF – PTD dry, Thick (FT>200nm)

All photoresists shown below are also applicable for immersion lithography



SUMIRESIST™ ArF – PTD immersion, Thin (FT<200nm)

